Special Issue

Design, Modeling, Optimization and Control in Manufacturing Industries and Energy System

Message from the Guest Editors

This Special Issue on "Design, Modeling, Optimization and Control in Manufacturing Industries and Energy System" seeks high quality works that focus on the latest optimization and control processes in the manufacturing, energy and service industries. Topics include, but are not limited to, the following:

- System design and simulation (digital twin);
- Novel modeling methods;
- Process and system optimization;
- Ensemble approach and advanced control technology;
- Internet of things and energy management;
- Application in manufacturing, energy and service fields.

Guest Editors

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Deadline for manuscript submissions

closed (30 November 2023)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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